

2023 International Workshop on

IWDTF2023

DIELECTRIC THIN FILMS FOR FUTURE ELECTRON DEVICES

– SCIENCE AND TECHNOLOGY –

Oct. 23 – 25, 2023

Kanazawa Chamber of Commerce and Industry,
Ishikawa, Japan

Research Topics

FOCUS SESSION Functional Thin Films for AI Applications

FOCUS SESSION *h*-BN and 2-Dimensional-Layered Dielectrics

Emerging Memory and Applications

Advanced Channel Materials

Electrical and Optical Characterization

Functional Oxides and Interface

Channel Technologies

Ferroelectric Thin Films

SiC MOS Device and Processes

Widegap Semiconductor

Interfaces, Materials and Characterizations

Abstract submission



OPEN: Jun. 1, 2023

CLOSE: Jul. 31, 2023

<http://iwdtf.org>

IWDTF2023 Committee

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Steering Chair: Shinji MIGITA (AIST)

Program Chair: Shun-ichiro OHMI (Tokyo Tech.)

Sponsored by JSAP Thin Film and Surface Physics Division